

Formamide Monomers And Polymers Synthesized Therefrom

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The Invention

Formamide group-containing monomers and polymers made by polymerizing the monomers are provided. Also provided are methods of polymerizing the monomers and methods of synthesizing functionalized polymers by pre- and/or post-polymerization functionalization. The monomers are non-toxic and can generate highly reactive isocyanate and isonitrile precursors in a one-pot synthesis that enables the incorporation of complex functionalities into the side-chain of the polymers that are synthesized from the monomers.

Additional Information

For More Information About the Inventors

• Padma Gopalan

Tech Fields

• Materials & Chemicals : Polymers

For current licensing status, please contact Jeanine Burmania at jeanine@warf.org or 608-960-9846